



24th RD50 Workshop
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Status of Silicon Strip Sensor Measurements at Liverpool

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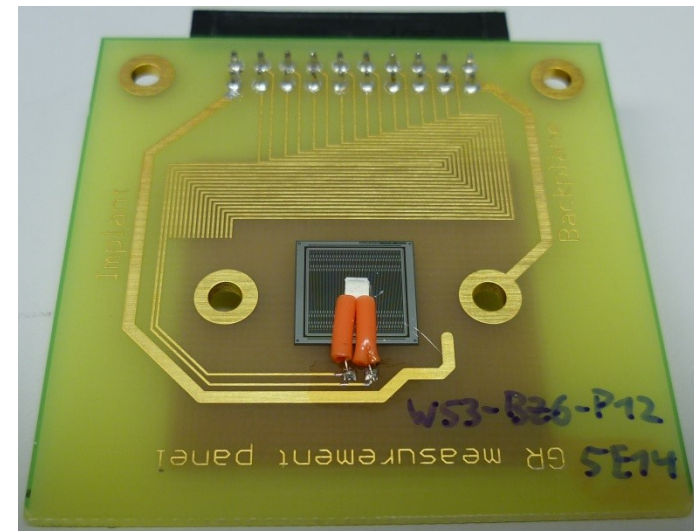
- Activation energy (E_g) and current related damage rate (α) determination through IV measurements of irradiated HPK and Micron sensors with fluences up to $2 \times 10^{16} \text{ n}_{\text{eq}}/\text{cm}^2$
- TCT and eTCT measurements of RD50 charge multiplication sensors (Micron)



IV Study



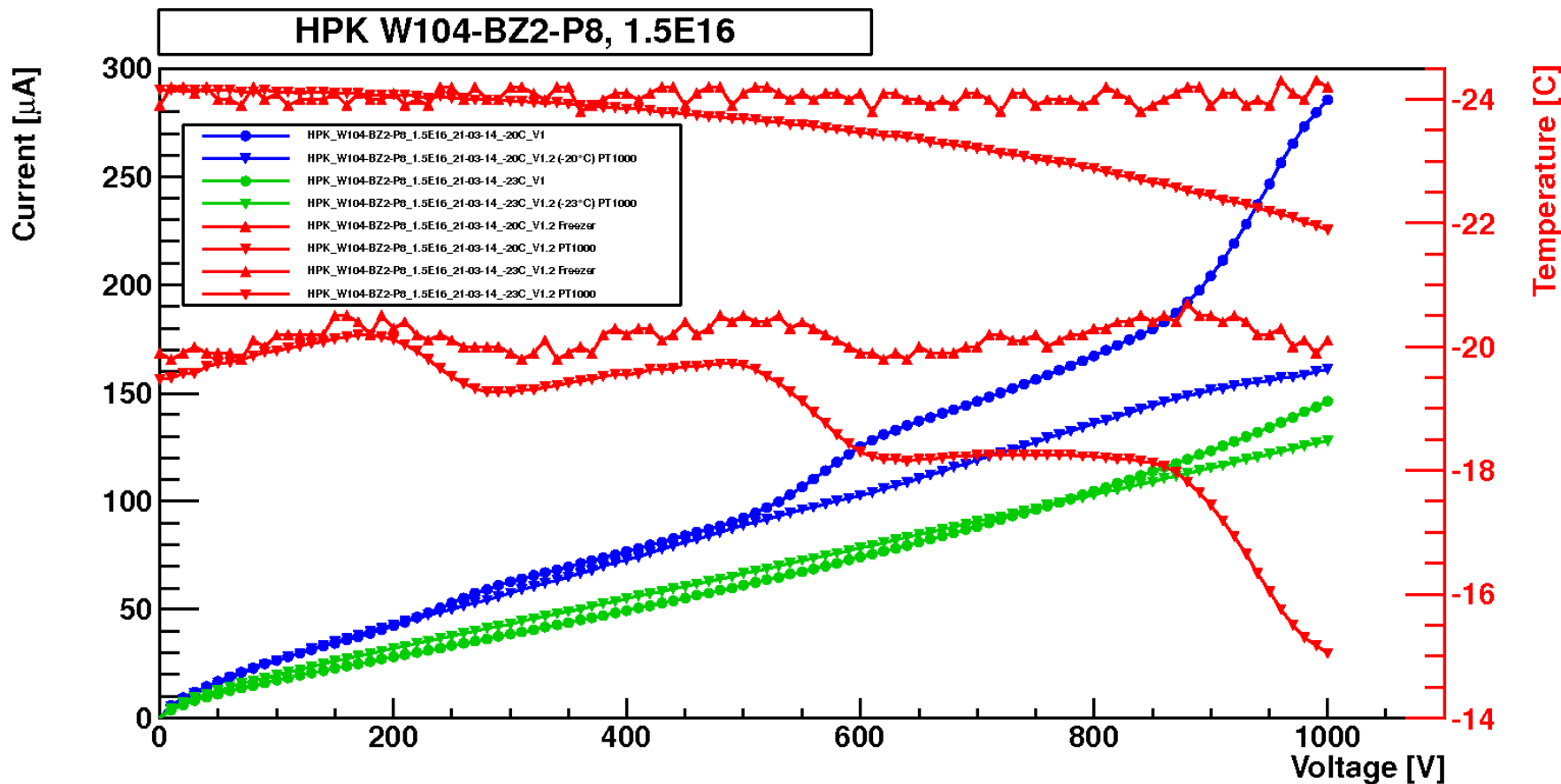
- Silicon sensors irradiated to different fluences
 - **ATLAS07 MINI**: 1×10^{12} , 5×10^{12} , 1×10^{13} , 5×10^{13} , 1×10^{14} , 5×10^{14} , 1×10^{15} , 5×10^{15} , 1×10^{16} , 1.5×10^{16} , 2×10^{16} [n_{eq}/cm^2]
 - **Micron 2437 (143 μ m)**: 5×10^{15} , 1×10^{16} , 2×10^{16} [n_{eq}/cm^2]
 - **Micron 2923 (108 μ m)**: 5×10^{15} , 1×10^{16} , 2×10^{16} [n_{eq}/cm^2]
- One set of sensors measured at Liverpool, second set send to Lancaster
- PT1000 temperature sensor glued on silicon
- IV measurements in freezer at different temperatures from -23°C to -15°C (at least 2 per sensor)





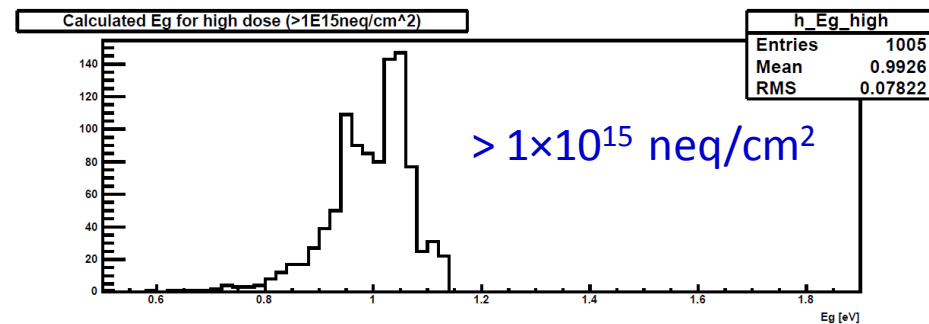
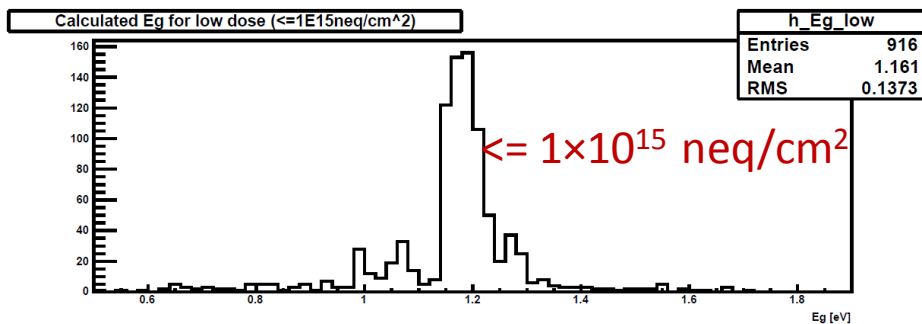
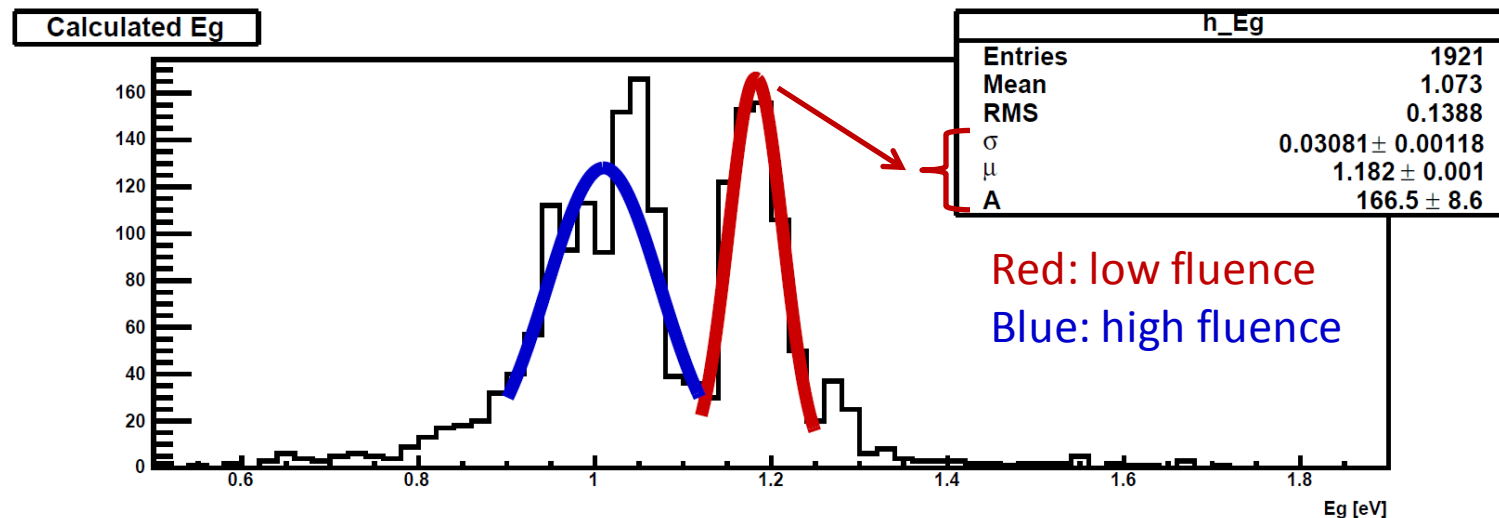
Self-Heating

For samples irradiated to more than $1 \times 10^{15} n_{eq}/cm^2$, the temperature increase of the sensor due to high current at higher voltages is clearly visible.

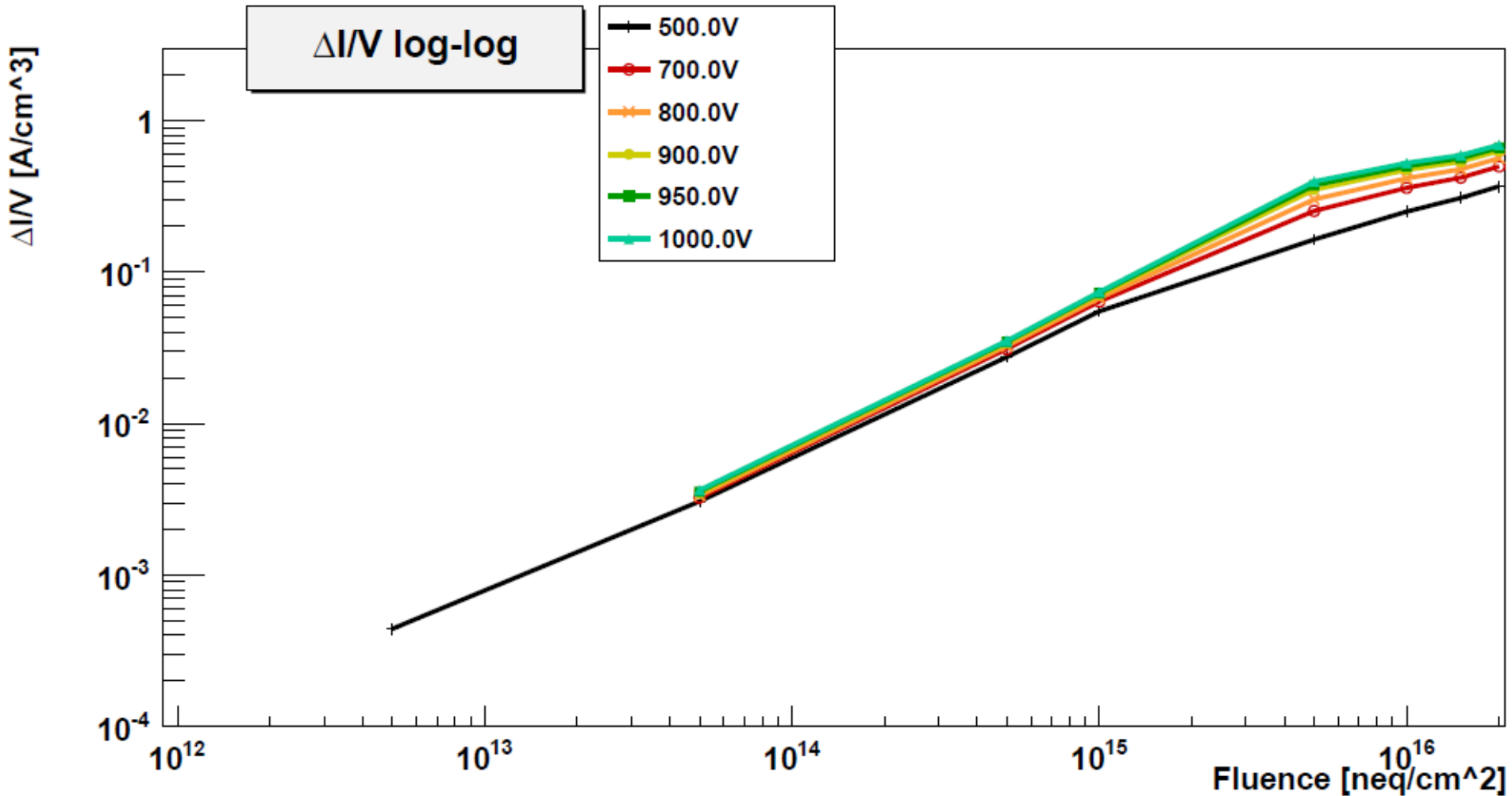




E_g Histogram

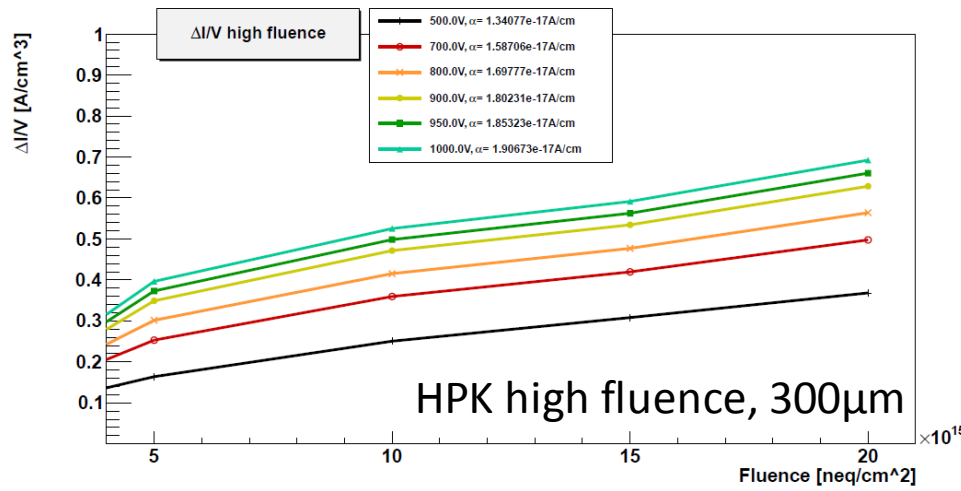
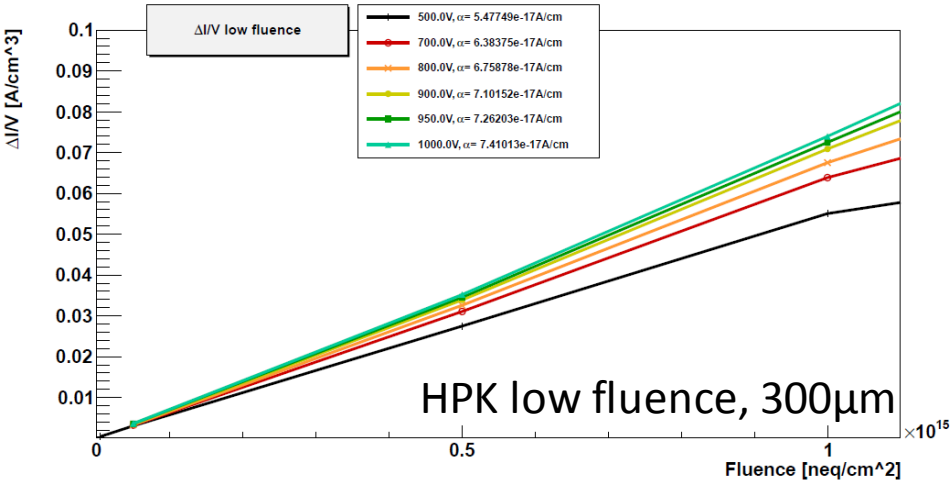


- E_g from Gauss fit for low fluence: **$(1.18 \pm 0.03) \text{ eV}$** in good agreement with literature value $(1.214 \pm 0.014) \text{ eV}$
- But: for higher fluences E_g significantly smaller **$(1.01 \pm 0.06) \text{ eV}$**

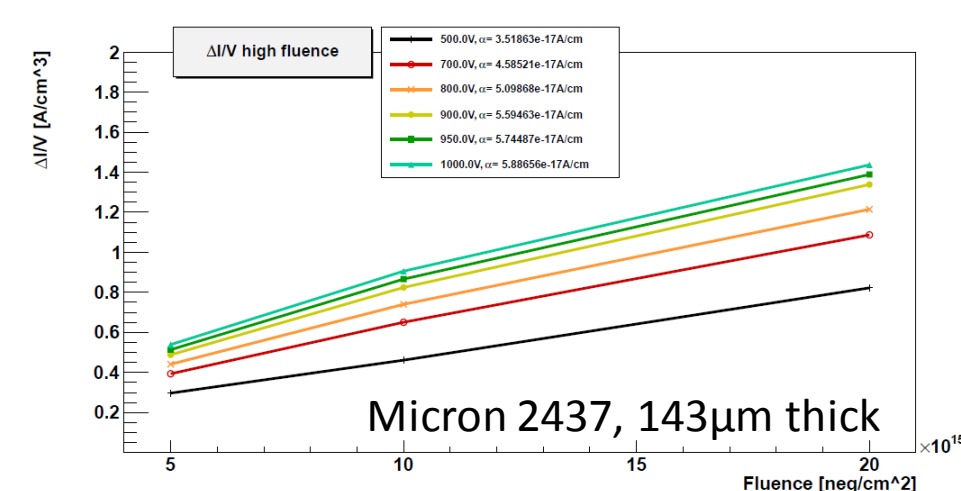
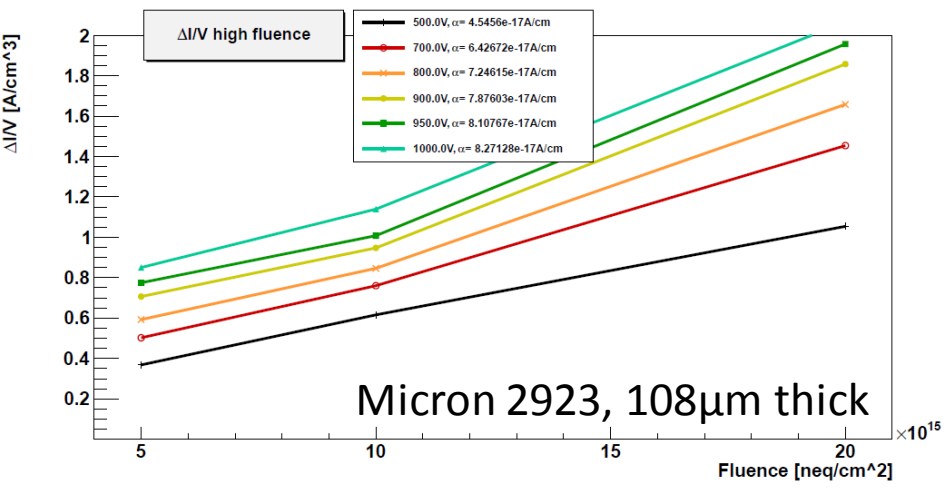




Volume Current (linear)



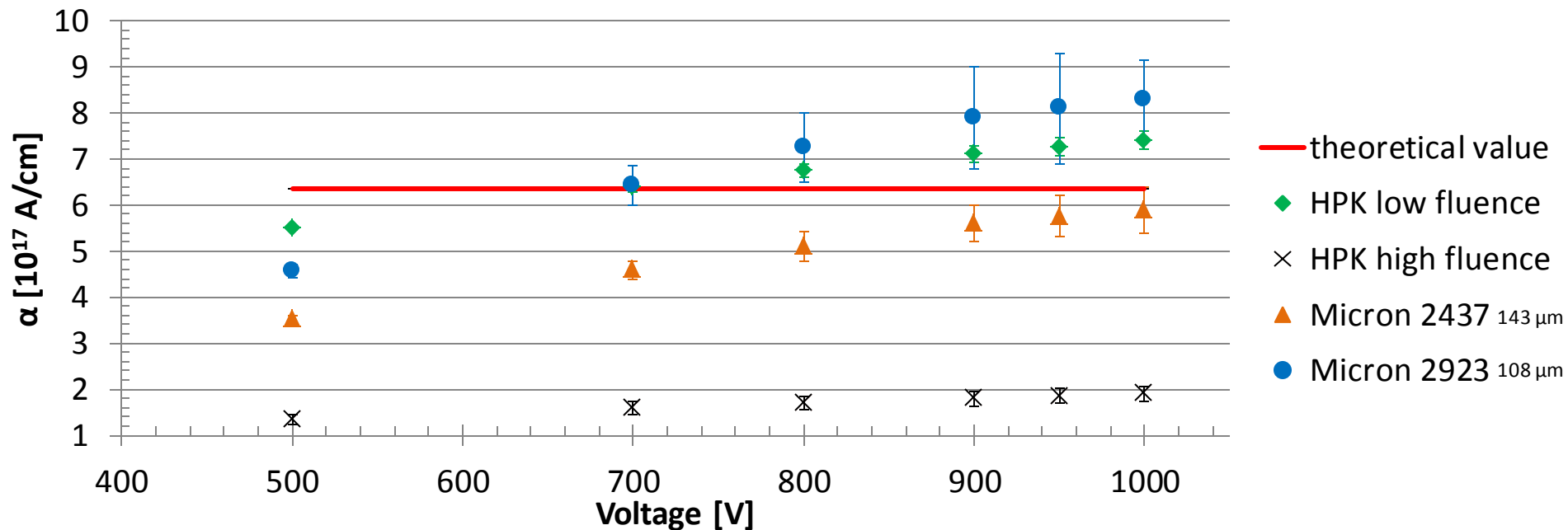
Fit straight line to graphs for α determination





Alpha Values

- Theoretical Value (420min annealing at 21°C): $6.371 \times 10^{-17} \text{ A/cm}$
- Literature value for E_g for temperature scaling of current
- Used “depleted” area:
 - HPK: $(0.8348 \times 0.86) \text{ cm}^2$, 293 μm thickness
 - Micron: $(1.0985 \times 1.0973) \text{ cm}^2$, 143/108 μm thickness (Micron 2437/2923)



Problem: Alpha depends on current and current depends on $E_g \Rightarrow$ which E_g value for alpha calculation?



TCT and eTCT measurements

PRELIMINARY RESULTS



- Measure dedicated charge multiplication sensors, produced by Micron Semiconductor Ltd (UK)
- 1cm x 1cm, n-in-p FZ strip detectors
- Various strip pitch (P) and width (W)
- Irradiated to two different fluences
 - $1 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$
 - $5 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$

More details on sensors see:

- U. Parzefall; *A Long Term Study of Charge Multiplication*; 24th RD50 Workshop
- C. Betancout; *Charge Collection Measurements on Dedicated RD50 Charge Multiplication SSDs*; 23rd RD50 Workshop
- S. Wonsak; *Combined Measurement Results of dedicated RD50 Charge Multiplication Sensors*; 22nd RD50 Workshop



Two Transient Current Technique setups at CERN:

- TCT+
 - TCT top/bottom with red (660nm) and IR (1064nm) laser
 - eTCT with IR laser
- eTCT
 - eTCT with IR laser
- Read-out of 5th strip
- Edge scans from top (strip implants) to bottom (backside) of sensor

For more details see talk:

- C. Gallrapp; *TCT, eTCT and I-DLTS measurement setups at the CERN SSD Lab*; 24th RD50 Workshop

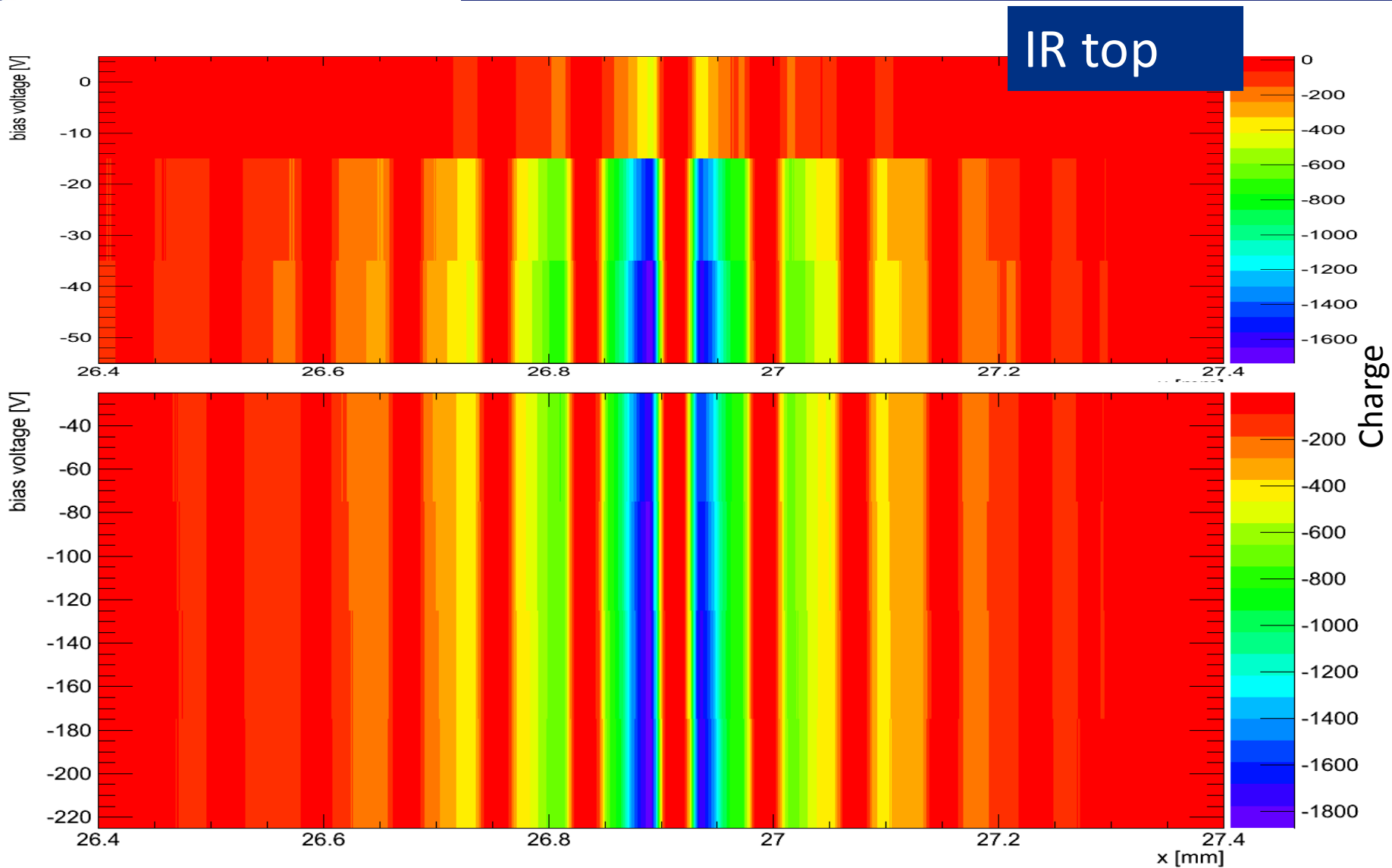


- First set of sensors measured with TCT+ and eTCT setup at CERN
 - No initial annealing
 - Liv-2488-7-1-15-H: more collected charge in ALiBaVa measurement than other sensors

Name	W-P [μm]	Dose [$n_{\text{eq}}/\text{cm}^2$]	TCT	eTCT
2328-16-CERN *	P80-W32	-	red, IR	TCT+
Liv-2935-7-1-15-L	P80-W6	1.00E+015	IR	TCT+
Liv-2935-7-1-15-H	P80-W6	5.00E+015		eTCT
Liv-2488-7-1-15-H	P80-W6	5.00E+015	IR	eTCT, TCT+
Liv-2935-7-3-1-L	P40-W15-I15 **	1.00E+015		eTCT

*: sensor for ALiBaVa calibration

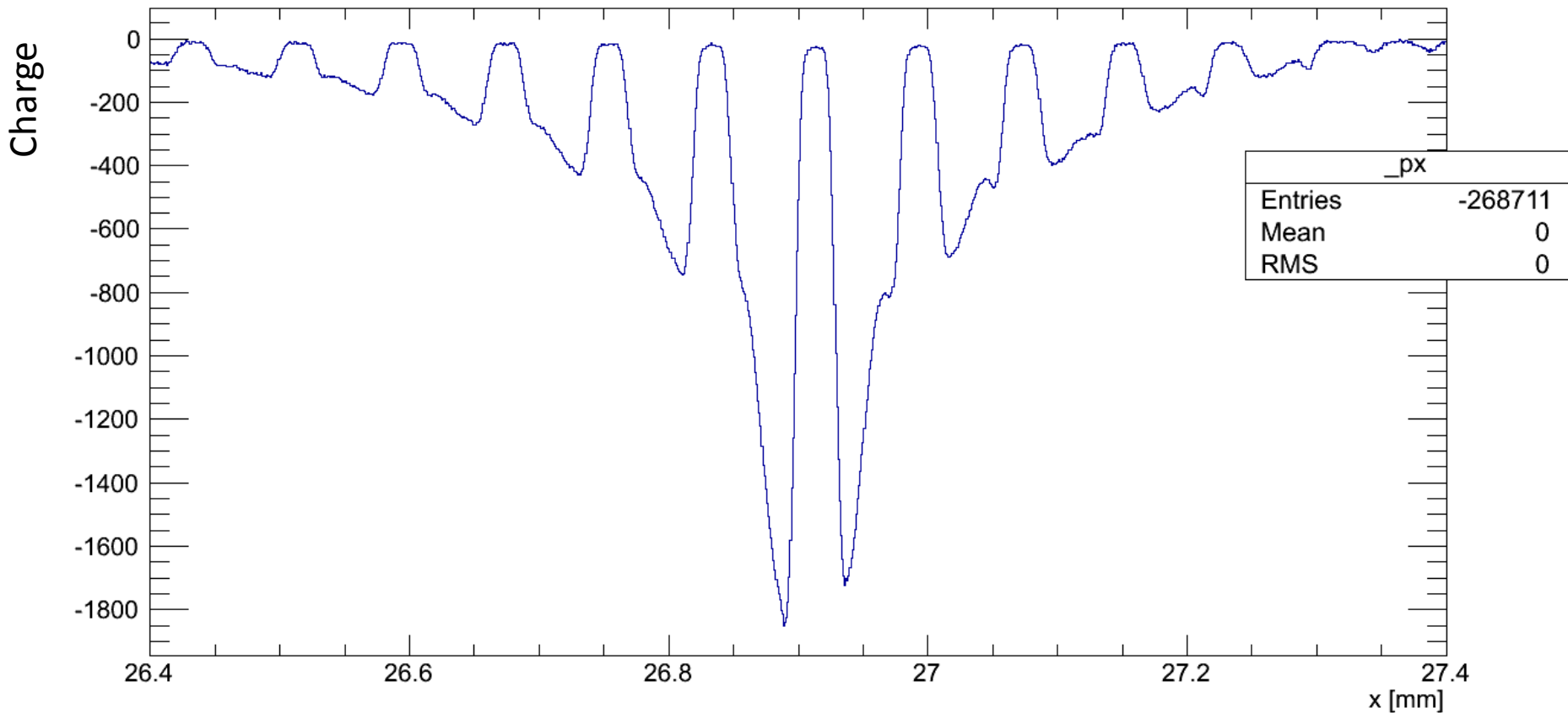
** : I15: biased intermediate strip with 15 μm width





IR top

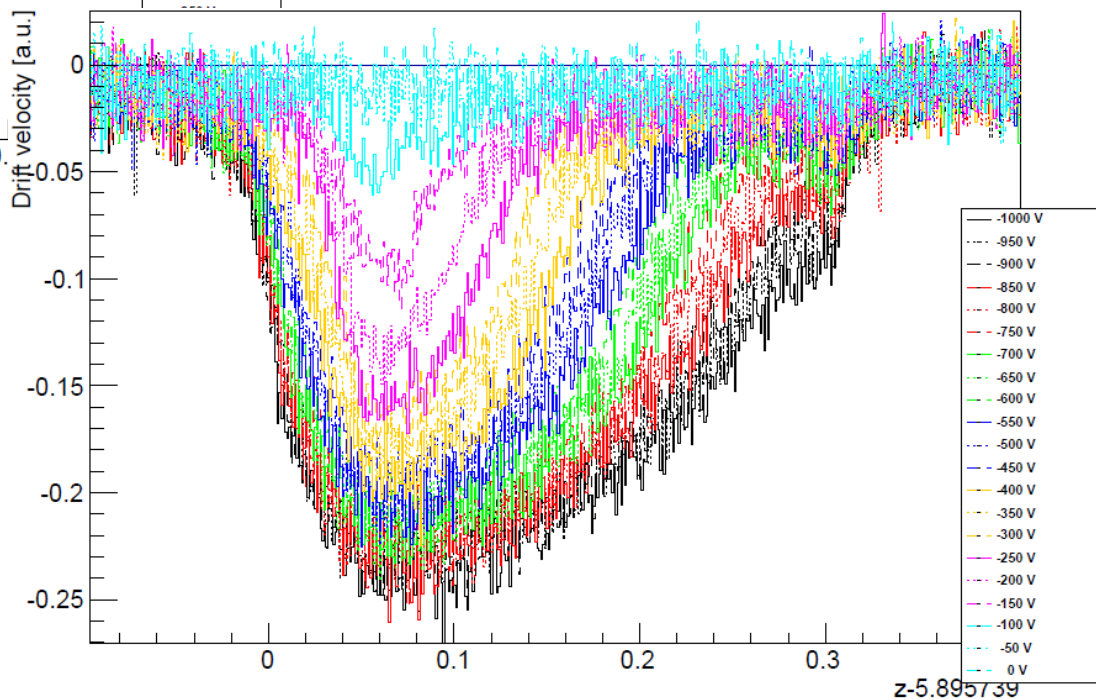
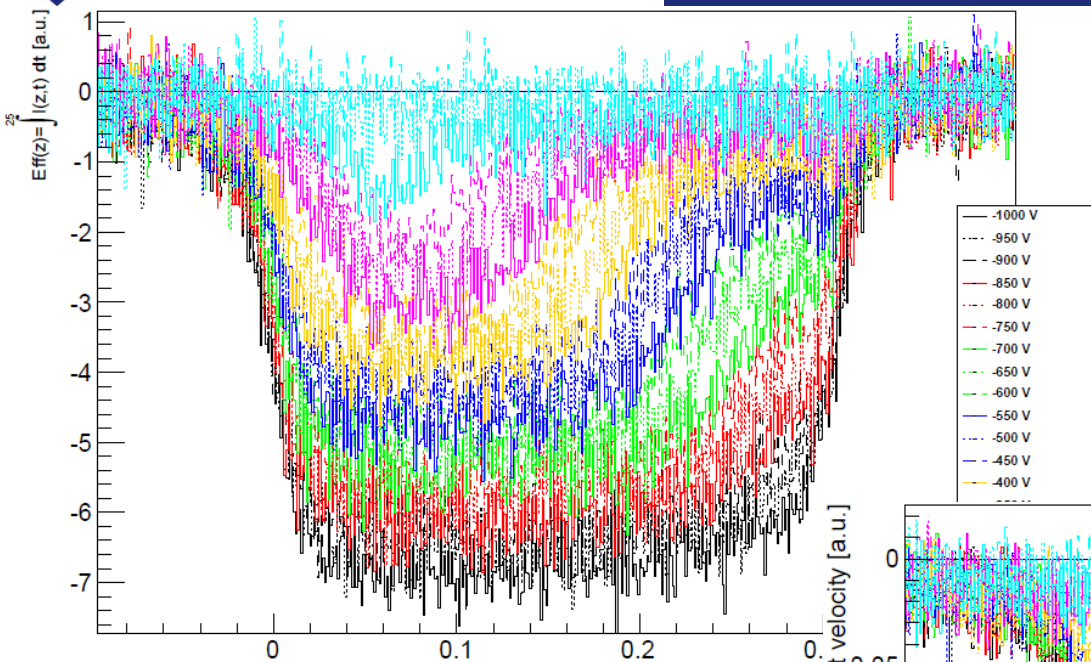
-200V

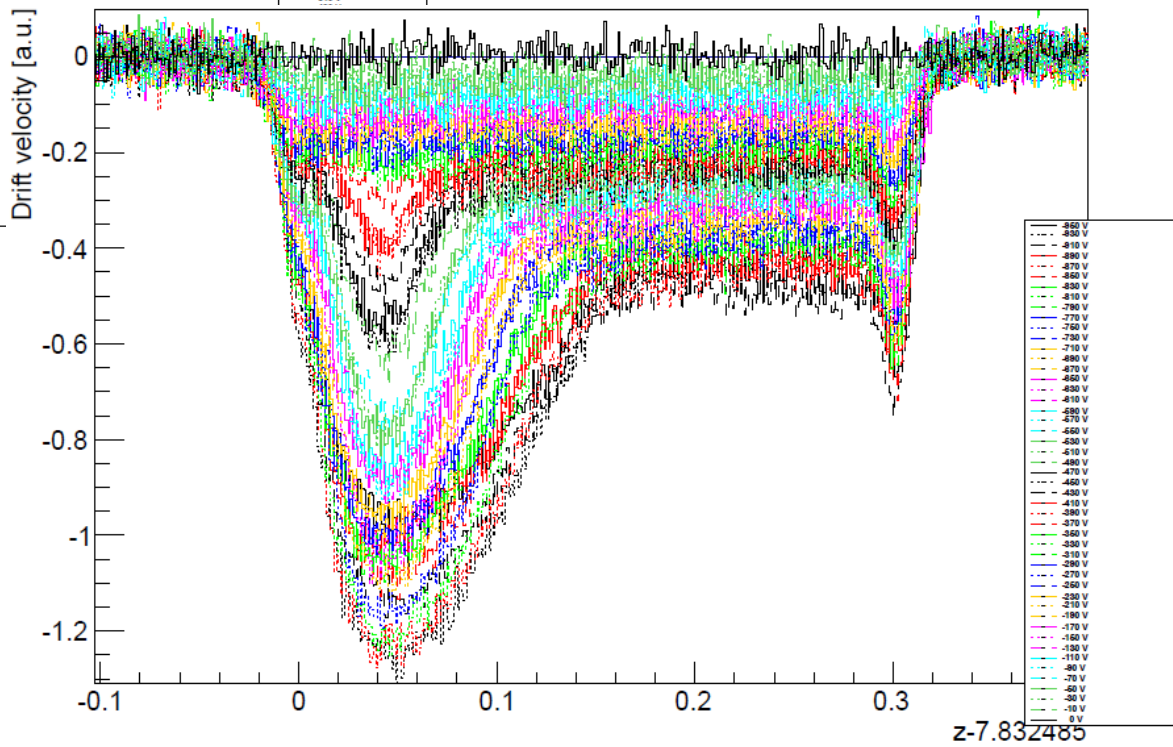
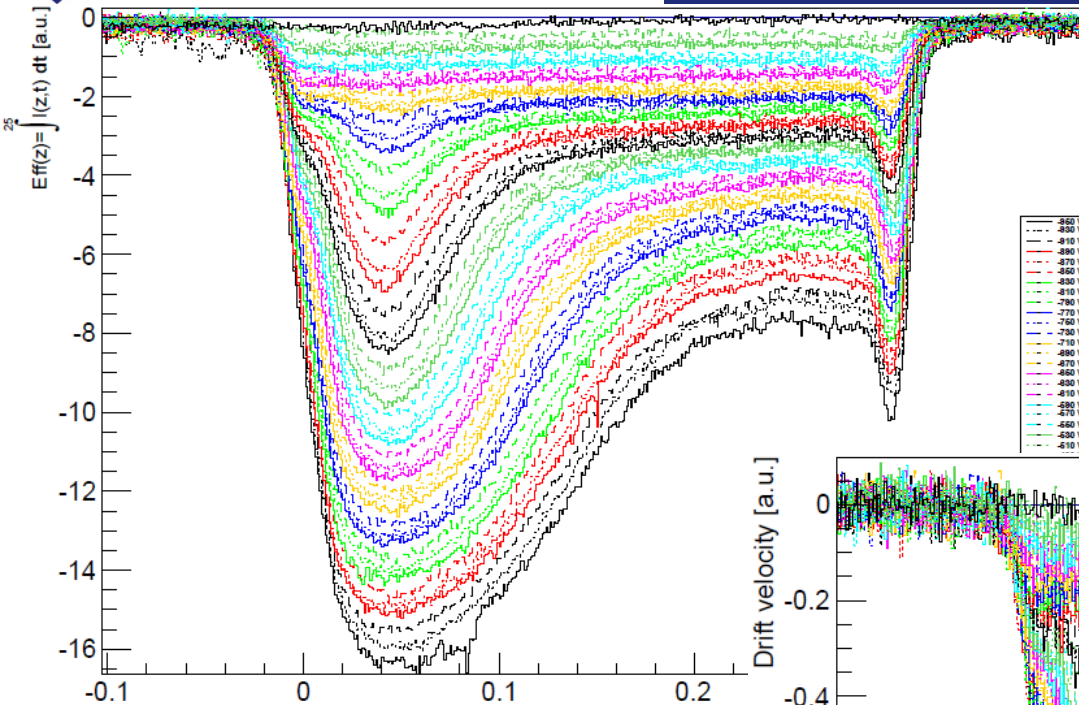




edge

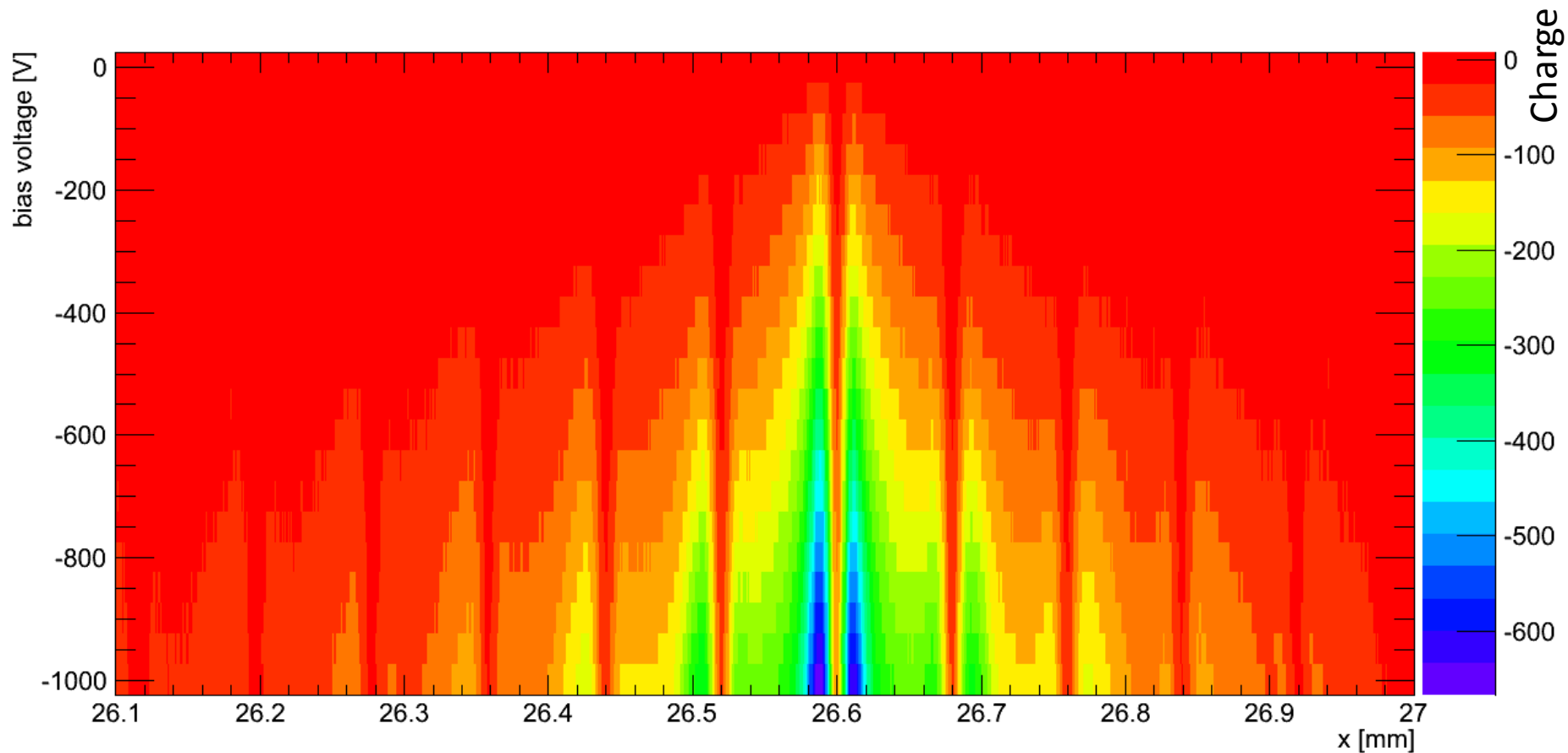
with TCT+







IR top

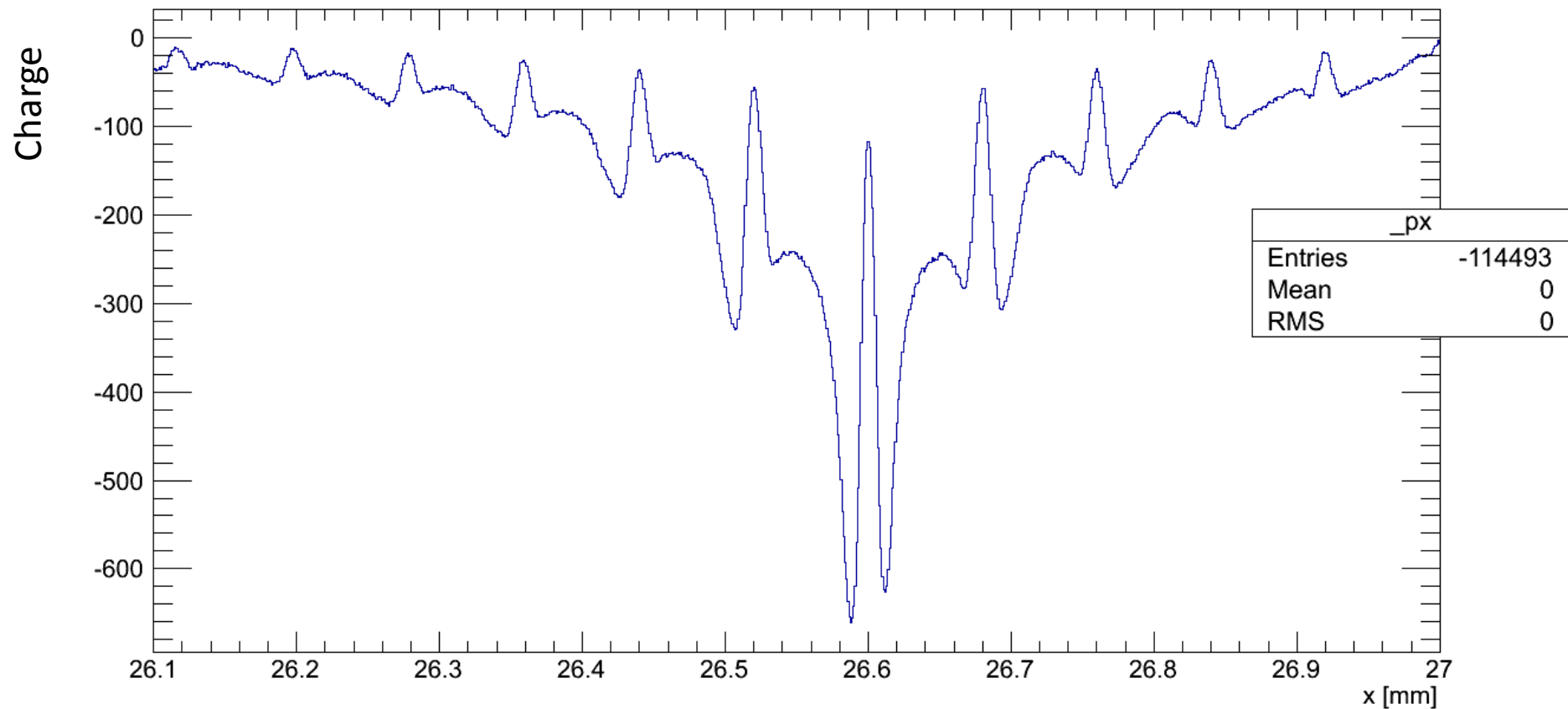


“more charge”



IR top

-1000V

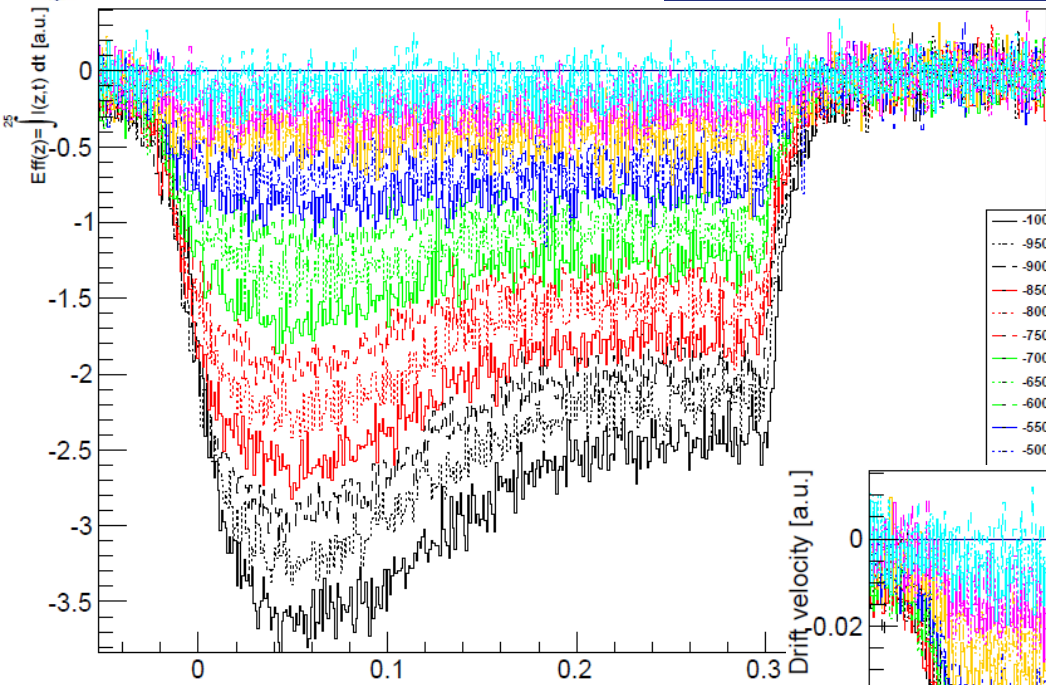


“more charge”

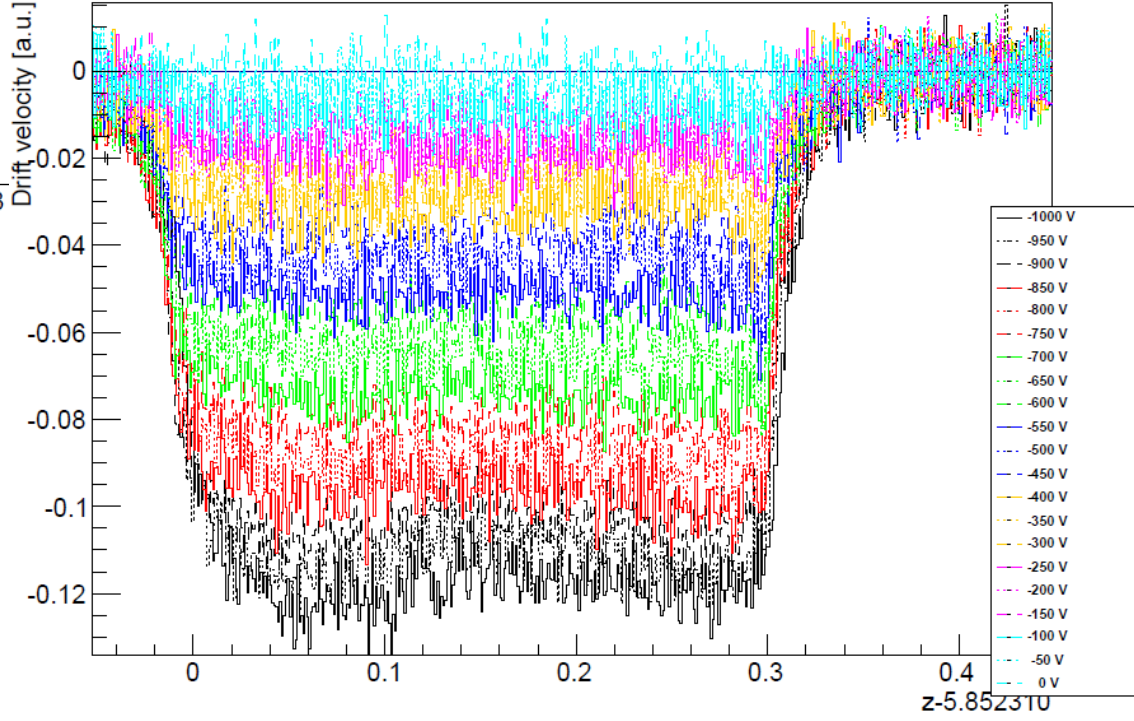


edge

with TCT+

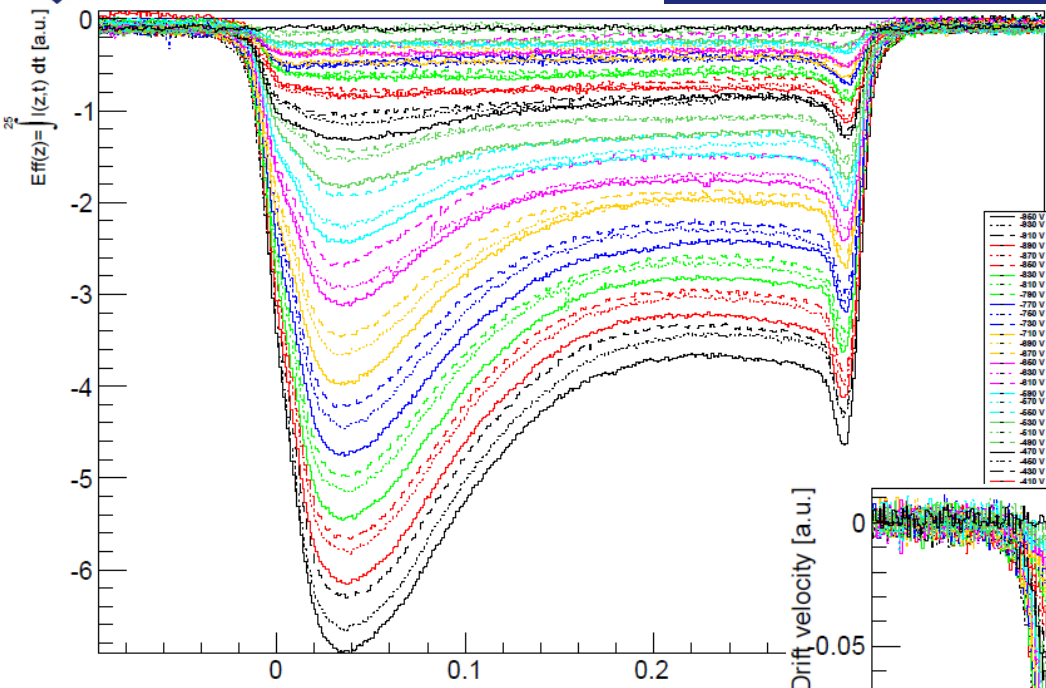


- 1000 V
- 950 V
- 900 V
- 850 V
- 800 V
- 750 V
- 700 V
- 650 V
- 600 V
- 550 V
- 500 V



- 1000 V
- 950 V
- 900 V
- 850 V
- 800 V
- 750 V
- 700 V
- 650 V
- 600 V
- 550 V
- 500 V
- 450 V
- 400 V
- 350 V
- 300 V
- 250 V
- 200 V
- 150 V
- 100 V
- 50 V
- 0 V

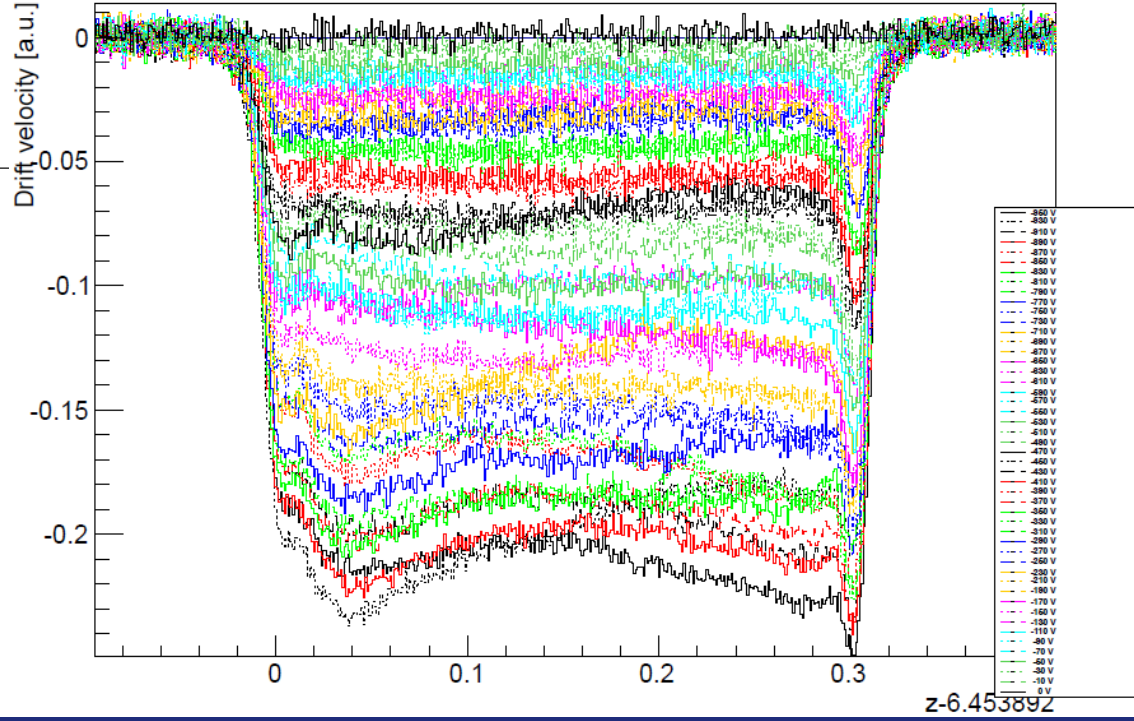
“more charge”



edge

No homogeneous efficiency
along sensor side:
Efficiency increase with
distance to pads

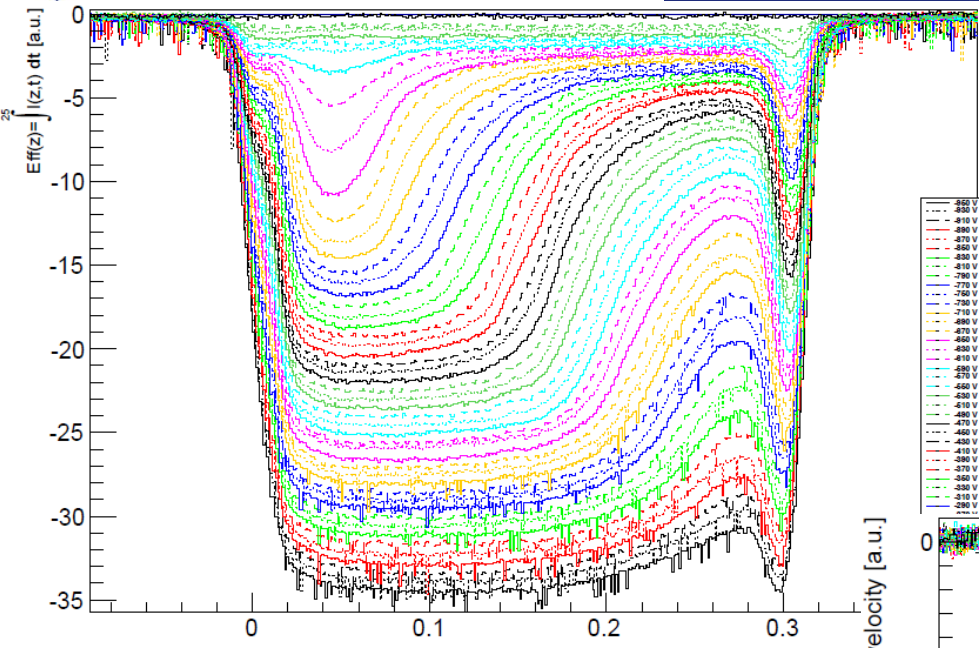
“more charge”



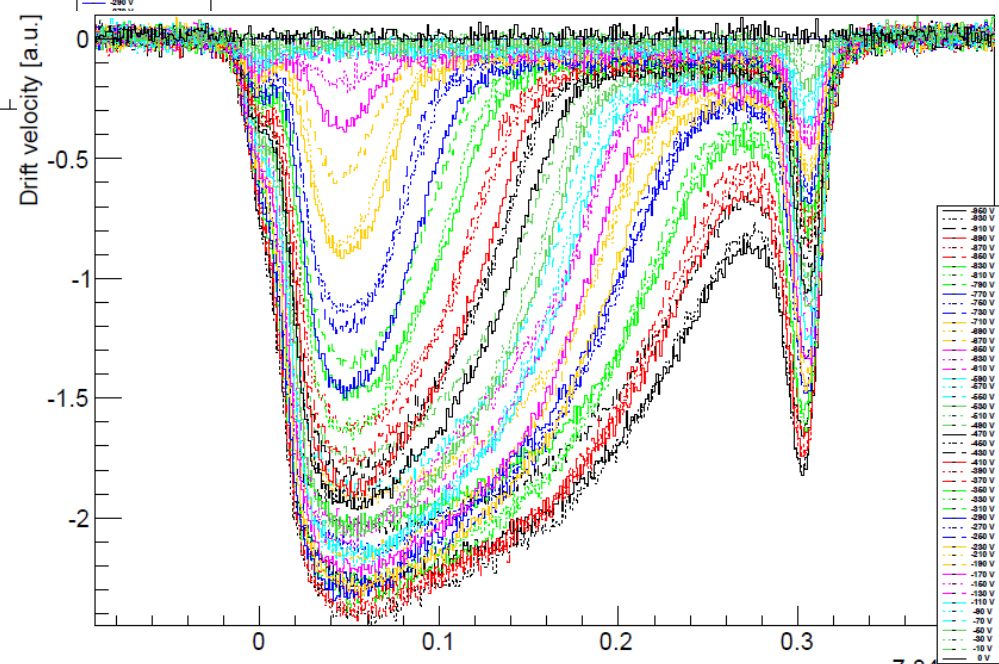
z-6.45389Z



edge



- 280 V
- 290 V
- 300 V
- 310 V
- 320 V
- 330 V
- 340 V
- 350 V
- 360 V
- 370 V
- 380 V
- 390 V
- 400 V
- 410 V
- 420 V
- 430 V
- 440 V
- 450 V
- 460 V
- 470 V
- 480 V
- 490 V



- 280 V
- 290 V
- 300 V
- 310 V
- 320 V
- 330 V
- 340 V
- 350 V
- 360 V
- 370 V
- 380 V
- 390 V
- 400 V
- 410 V
- 420 V
- 430 V
- 440 V
- 450 V
- 460 V
- 470 V
- 480 V
- 490 V

z-7.84135Z



- First IV measurements show a decrease in E_g for sensors irradiated with a fluence higher than $1 \times 10^{15} n_{eq}/cm^2$
- Current related damage range α :
 - HPK: factor 4 difference between low and high fluence; high fluence significant lower than expected
HPK low fluence 3σ agreement with expected value at 700V and 800V, but no saturation
 - 3σ agreement of Micron sensors ($\geq 900V$) with expected value, no saturation
- Need verification of results with second set of sensors
- Continue study with annealing of sensors
- First TCT/eTCT measurements of RD50 charge multiplication sensors are promising
- More measurements will follow



- I would like to thank the irradiation teams at Ljubljana and Birmingham.
- Special thanks go to Christian, Marcos, Hannes and Michael at CERN for helping with the TCT measurements and sharing their setups.



Backup



- IV scaling:

$$\frac{I(T_2)}{I(T_1)} = \left(\frac{T_2}{T_1}\right)^2 \exp\left(\frac{-E_g}{2k_B} \frac{T_1 - T_2}{T_1 T_2}\right)$$

E_g : activation energy (1.214±0.014eV [1]); T_1 : measurement temperature, T_2 : scaling temperature; k_B : Boltzmann constant

Use for scaling of current to different temperatures, determination of E_g from measurement

- Investigate behaviour of current for irradiated sensors

$$\frac{I(\Phi_{eq}) - I(\Phi_0)}{V} = \alpha \Phi_{eq}$$

Only valid up to
 $\sim 1 \times 10^{15} \text{ n}_{eq}/\text{cm}^2$

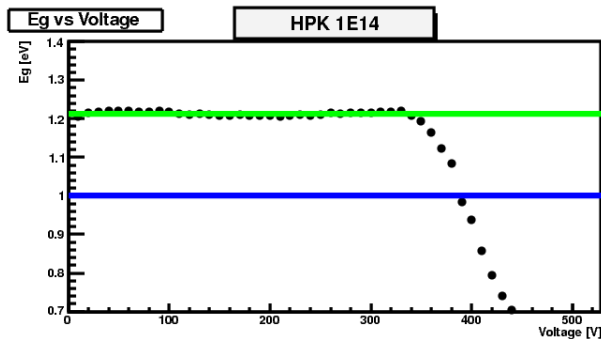
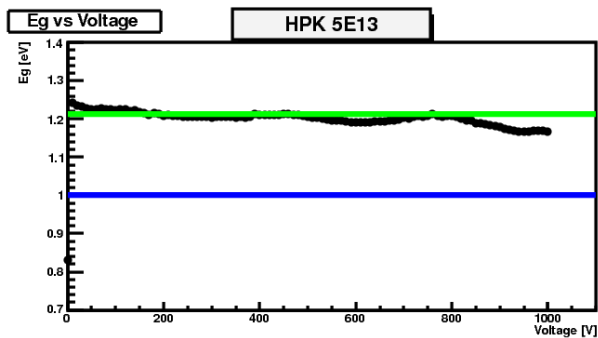
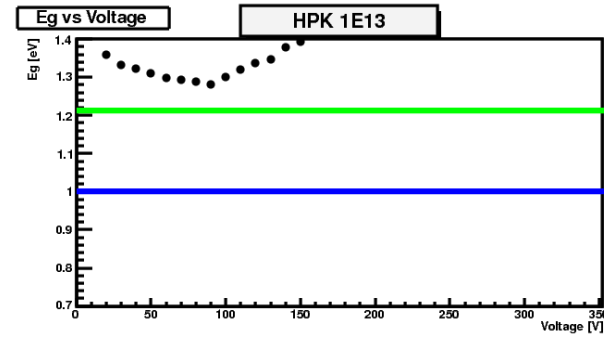
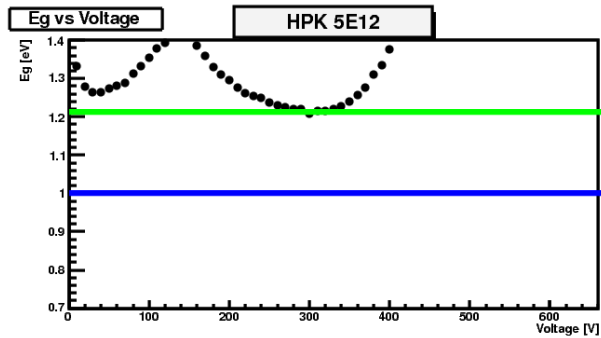
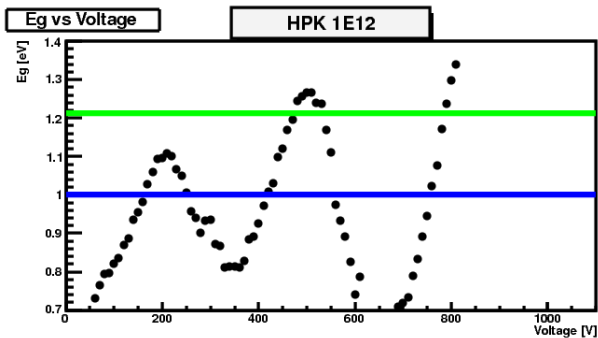
V : depleted volume; Φ_{eq} : equivalent fluence; $I(\Phi_0)$: nonirradiated current ; α : current related damage rate

Determination of α from measurements

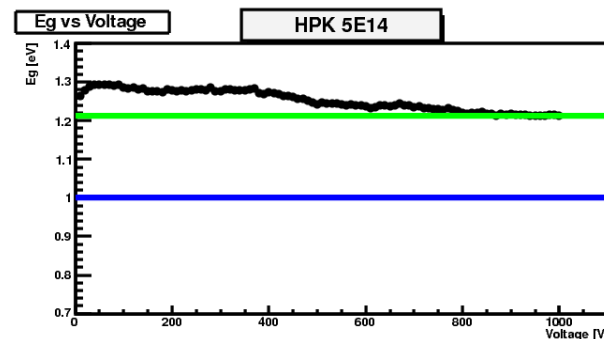
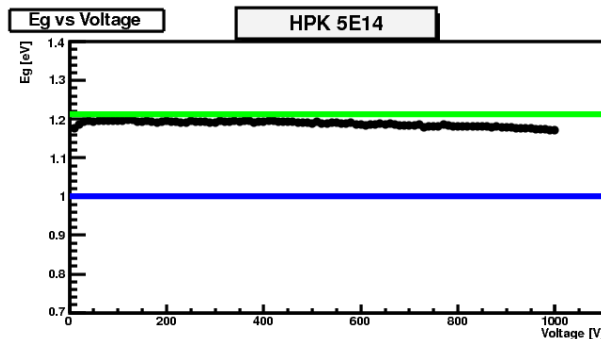
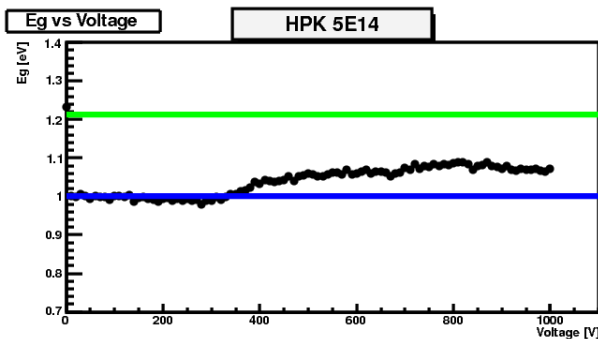
[1]: A. Chilingarov; *Temperature dependence of the current generated in Si bulk*; **2013_JINST_8_P10003**



E_g Details I (HPK)

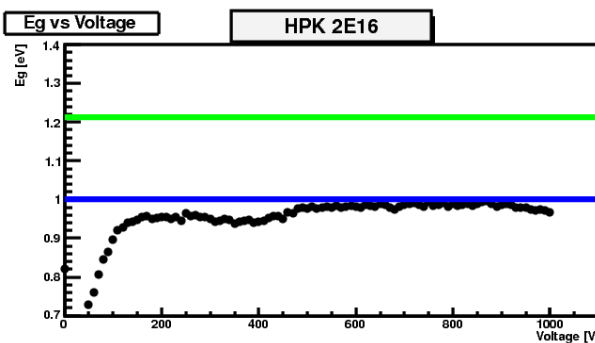
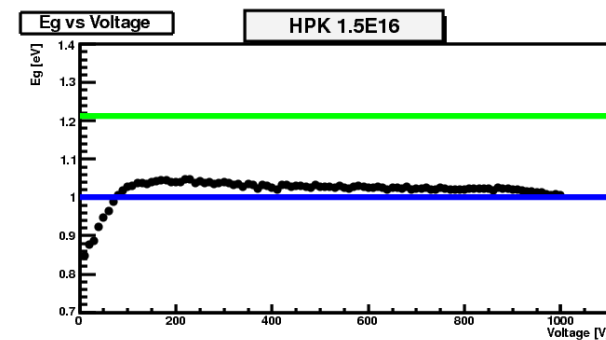
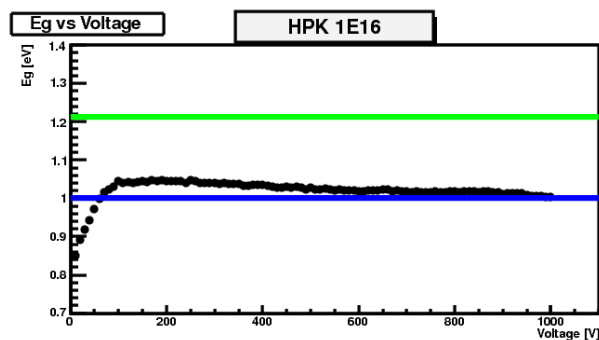
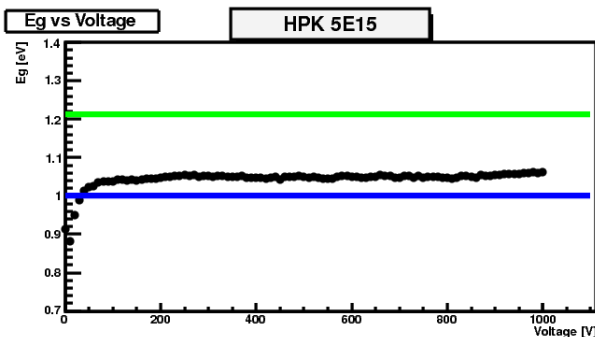
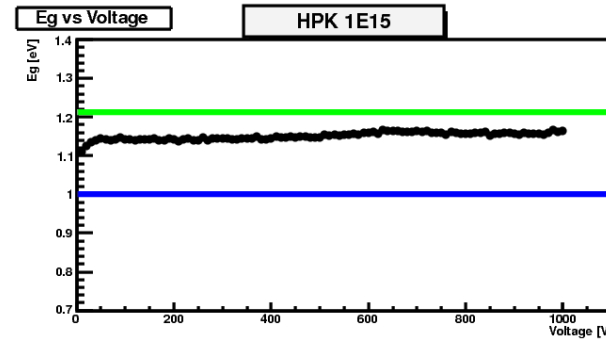
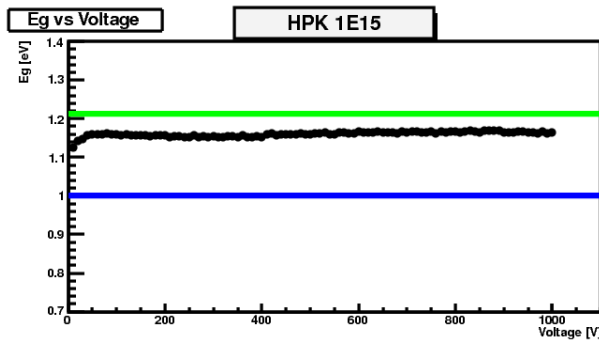
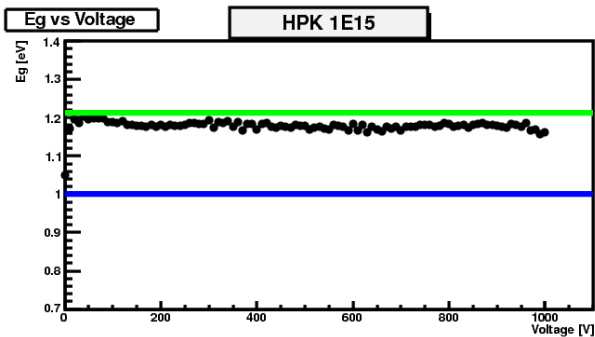


$E_g \approx 1.2\text{eV}$ (green line)
for most sensors
(also next slide)





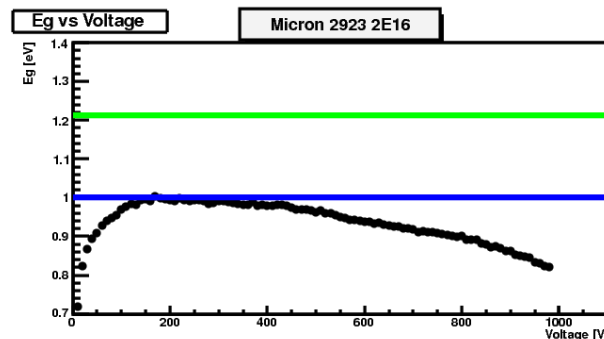
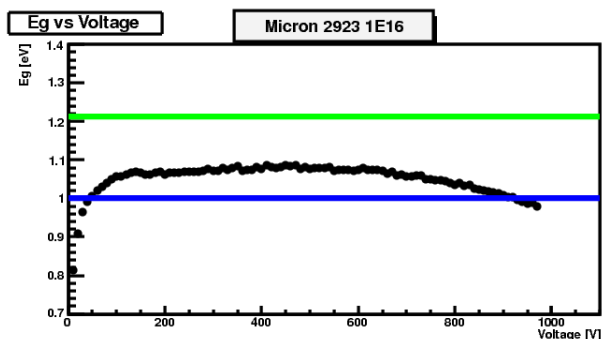
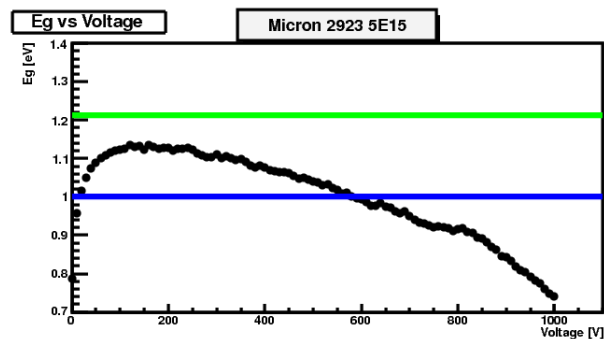
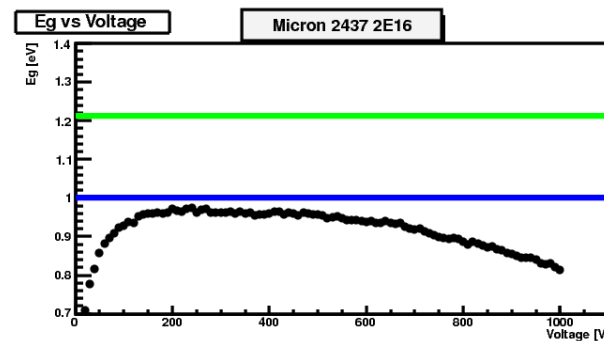
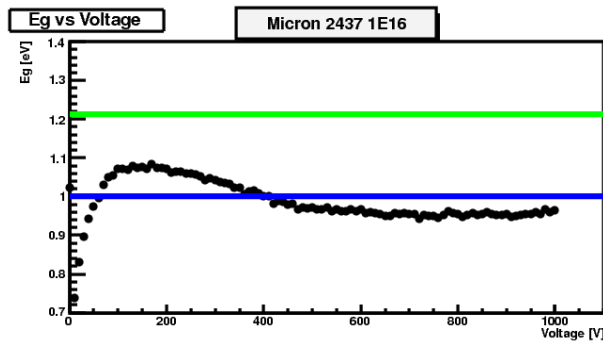
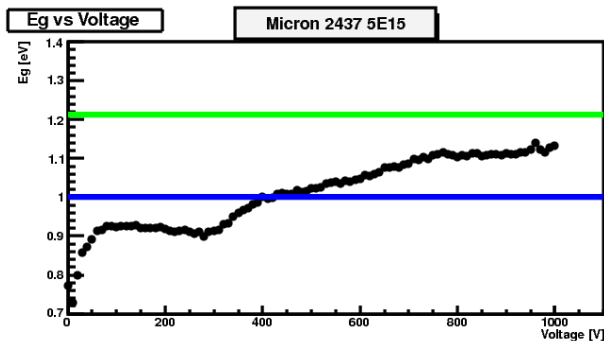
E_g Details II (HPK)



Sensors irradiated to 1×10^{15} , 5×10^{15} , 1×10^{16} , 1.5×10^{16} , 2×10^{16} n_{eq}/cm^2 clearly lower $E_g \approx 1eV$ (blue line) than lower dose



E_g Details III (Micron)



Also for Micron sensors (143 μ m (upper row) and 108 μ m (lower row) thick) E_g for higher doses closer to 1eV (blue line) than to 1.2eV (green line)

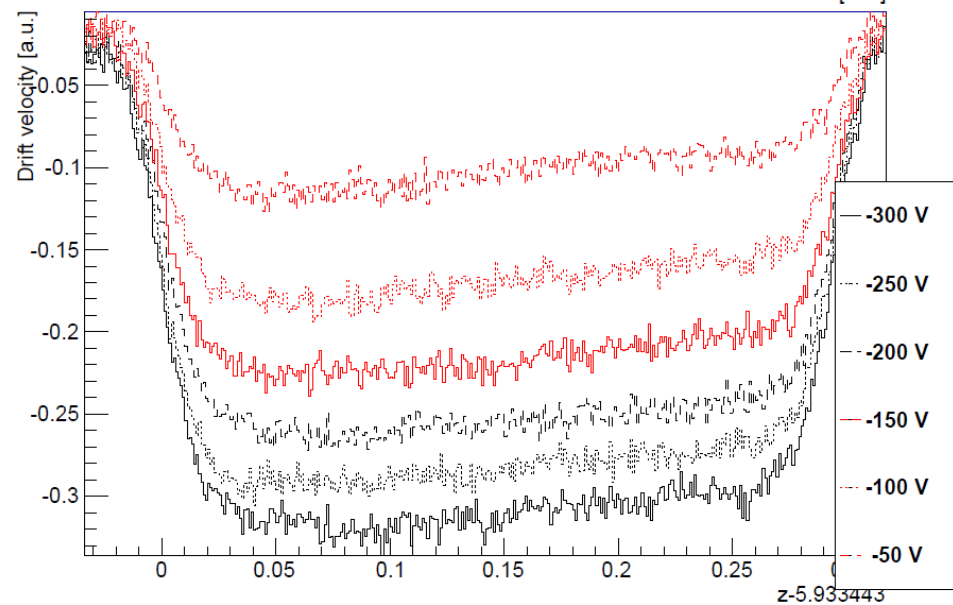
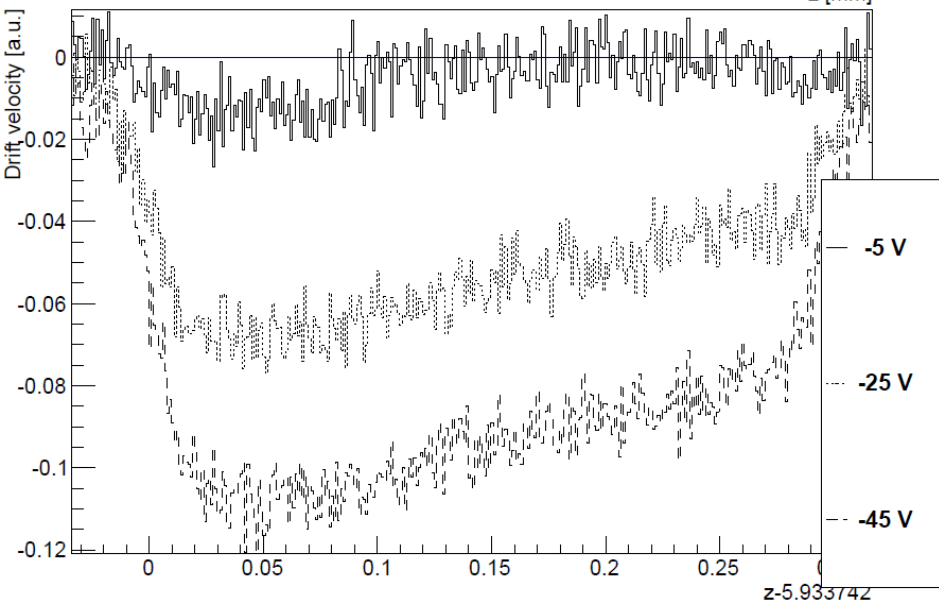
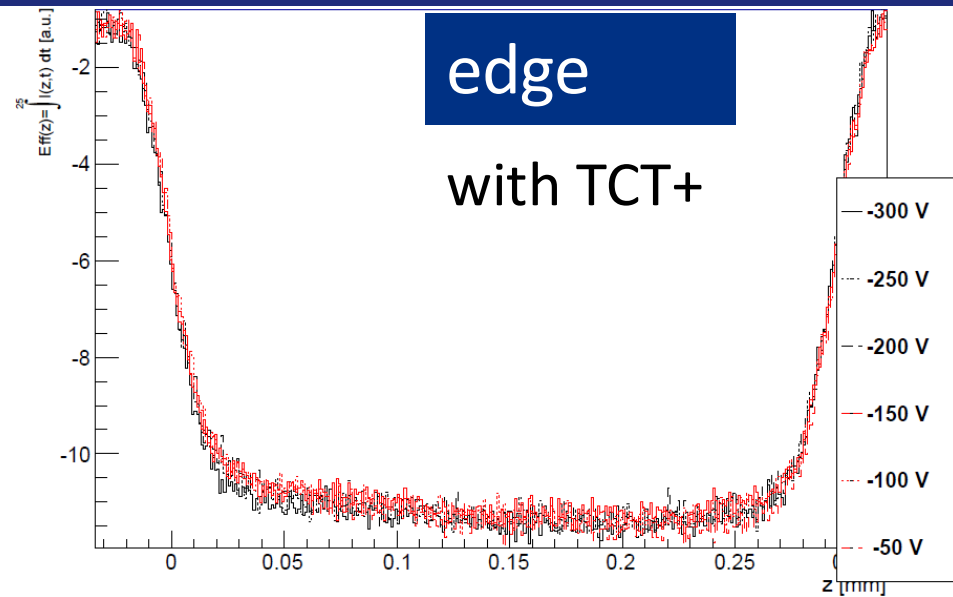
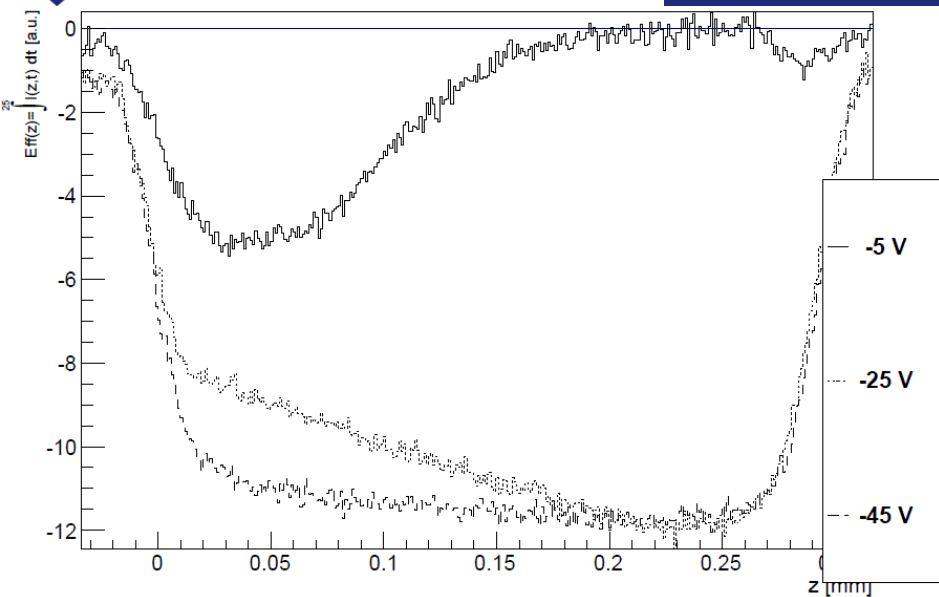


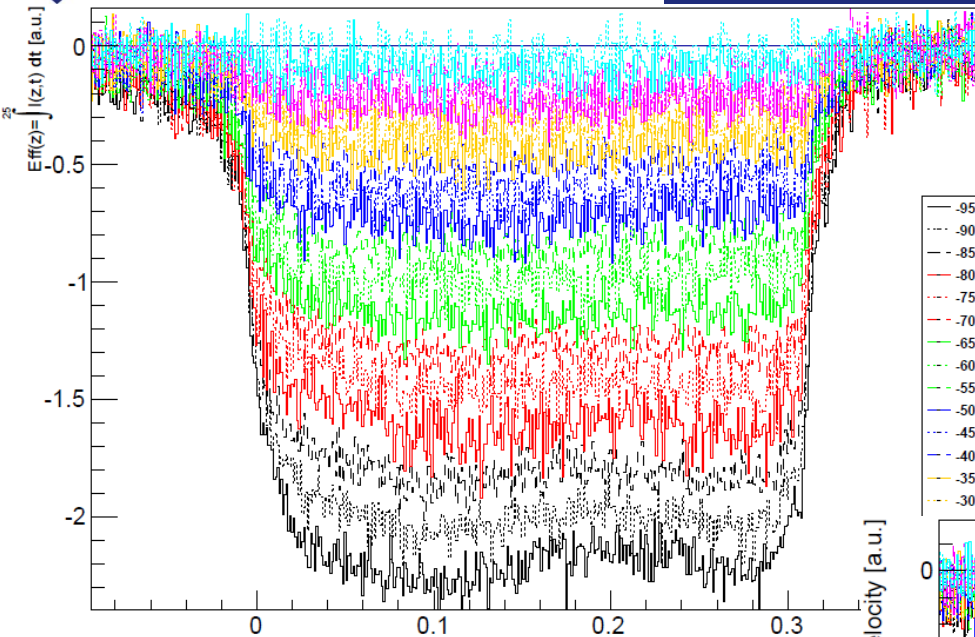
- Theoretical Value (420min annealing at 21°C): $6.371 \times 10^{-17} \text{ A/cm}$
- Literature value for α for temperature scaling
- Used “depleted” area:
 - HPK: $(0.8348 \times 0.86) \text{ cm}^2$, 293 μm thickness
 - Micron: $(1.0985 \times 1.0973) \text{ cm}^2$, 143/108 μm thickness (Micron 2437/2923)

Voltage [V]	HPK [$\times 10^{17}$ A/cm]		Micron [$\times 10^{17}$ A/cm]	
	Low fluence	High fluence	2437	2923
500	5.477 \pm 0.015	1.341 \pm 0.095	3.519 \pm 0.079	4.55 \pm 0.14
700	6.38 \pm 0.11	1.59 \pm 0.13	4.59 \pm 0.19	6.43 \pm 0.44
800	6.76 \pm 0.14	1.70 \pm 0.14	5.10 \pm 0.31	7.25 \pm 0.75
900	7.10 \pm 0.18	1.80 \pm 0.16	5.60 \pm 0.39	7.9 \pm 1.1
950	7.26 \pm 0.2	1.85 \pm 0.16	5.75 \pm 0.45	8.1 \pm 1.2
1000	7.41 \pm 0.21	1.91 \pm 0.16	5.89 \pm 0.50	8.27 \pm 0.86

Green: 3 σ agreement with theoretical value

Problem: Alpha depends on current and current depends on $E_g \Rightarrow$ which E_g value for alpha calculation?

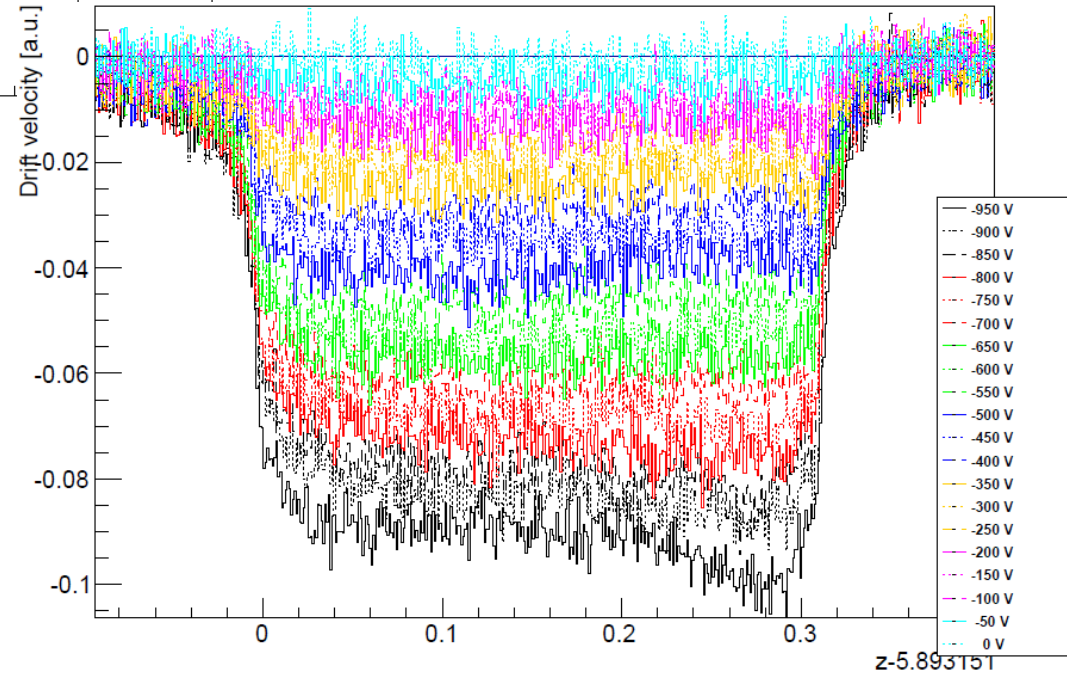




- -950 V
- -900 V
- -850 V
- -800 V
- -750 V
- -700 V
- -650 V
- -600 V
- -550 V
- -500 V
- -450 V
- -400 V
- -350 V
- -300 V

edge

with TCT+;
Different
position



- -950 V
- -900 V
- -850 V
- -800 V
- -750 V
- -700 V
- -650 V
- -600 V
- -550 V
- -500 V
- -450 V
- -400 V
- -350 V
- -300 V
- -250 V
- -200 V
- -150 V
- -100 V
- -50 V
- 0 V

“more charge”

z-5.89315T